## John M Dell

## List of Publications by Year in descending order

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271 all docs

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271

2489 citing authors

#	Article	IF	CITATIONS
1	Effect of deposition conditions on mechanical properties of low-temperature PECVD silicon nitride films. Materials Science & Engineering A: Structural Materials: Properties, Microstructure and Processing, 2006, 435-436, 453-459.	5.6	161
2	Scattering mechanisms limiting two-dimensional electron gas mobility in Al0.25Ga0.75N/GaN modulation-doped field-effect transistors. Journal of Applied Physics, 2000, 87, 3900-3904.	2.5	126
3	Widely Tunable MEMS-Based Fabry–Perot Filter. Journal of Microelectromechanical Systems, 2009, 18, 905-913.	2.5	106
4	/sup 60/Co gamma irradiation effects on n-GaN Schottky diodes. IEEE Transactions on Electron Devices, 2003, 50, 2326-2334.	3.0	96
5	Nanoscratch-induced phase transformation of monocrystalline Si. Scripta Materialia, 2010, 63, 847-850.	5.2	86
6	MEMS-based microspectrometer technologies for NIR and MIR wavelengths. Journal Physics D: Applied Physics, 2009, 42, 133001.	2.8	80
7	Determination of mechanical properties of PECVD silicon nitride thin films for tunable MEMS Fabry–Pérot optical filters. Journal of Micromechanics and Microengineering, 2005, 15, 608-614.	2.6	71
8	60Co gamma-irradiation-induced defects in n-GaN. Applied Physics Letters, 2002, 80, 4354-4356.	3.3	66
9	Quantifying the Effects of 16p11.2 Copy Number Variants on Brain Structure: A Multisite Genetic-First Study. Biological Psychiatry, 2018, 84, 253-264.	1.3	56
10	Monolithic integration of an infrared photon detector with a MEMS-based tunable filter. IEEE Electron Device Letters, 2005, 26, 888-890.	3.9	54
11	HgCdTe mid-wavelength IR photovoltaic detectors fabricated using plasma induced junction technology. Journal of Electronic Materials, 2000, 29, 841-848.	2.2	53
12	Nanoscratch-induced deformation of single crystal silicon. Journal of Vacuum Science & Technology B, 2009, 27, 1374-1377.	1.3	48
13	Magnetic field dependent Hall data analysis of electron transport in modulation-doped AlGaN/GaN heterostructures. Journal of Applied Physics, 1997, 82, 2996-3002.	2.5	47
14	Tunable Fabry-P $\tilde{A}$ ©rot cavities fabricated from PECVD silicon nitride employing zinc sulphide as the sacrificial layer. Journal of Micromechanics and Microengineering, 2001, 11, 589-594.	2.6	46
15	GaSb: A New Alternative Substrate for Epitaxial Growth of HgCdTe. Journal of Electronic Materials, 2014, 43, 2788-2794.	2.2	43
16	Mechanisms of infrared photoluminescence in HgTe/HgCdTe superlattice. Journal of Applied Physics, 2012, 112, 063512.	2.5	37
17	MBE Growth of Mid-wave Infrared HgCdTe Layers on GaSb Alternative Substrates. Journal of Electronic Materials, 2015, 44, 3180-3187.	2.2	37
18	Characterization of Hg0.7Cd0.3Te n- on p-type structures obtained by reactive ion etching induced p- to n conversion. Journal of Electronic Materials, 2000, 29, 837-840.	2.2	36

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19	Generation-recombination effects on dark currents in CdTe-passivated midwave infrared HgCdTe photodiodes. Journal of Applied Physics, 2005, 98, 014504.	2.5	36
20	Stress in low-temperature plasma enhanced chemical vapour deposited silicon nitride thin films. Smart Materials and Structures, 2006, 15, S29-S38.	3.5	36
21	Interpretation of current flow in photodiode structures using laser beam-induced current for characterization and diagnostics. IEEE Transactions on Electron Devices, 2006, 53, 23-31.	3.0	33
22	Development of an Alkaline-Compatible Porous-Silicon Photolithographic Process. Journal of Microelectromechanical Systems, 2011, 20, 418-423.	2.5	32
23	Junction depth measurement in HgCdTe using laser beam induced current (LBIC). Journal of Electronic Materials, 1999, 28, 603-610.	2.2	29
24	Effect of oxidation on the chemical bonding structure of PECVD SiNx thin films. Journal of Applied Physics, 2006, 100, 123516.	2.5	29
25	Nanoindentation of HgCdTe prepared by molecular beam epitaxy. Applied Physics Letters, 2005, 87, 251905.	3.3	28
26	Effects of deposition temperature on the mechanical and physical properties of silicon nitride thin films. Journal of Applied Physics, 2005, 98, 044904.	2.5	28
27	p-to-n type-conversion mechanisms for HgCdTe exposed to H2/CH4 plasmas. Journal of Electronic Materials, 2001, 30, 762-767.	2.2	27
28	Design and Characterization of Fabry–Pérot MEMS-Based Short-Wave Infrared Microspectrometers. Journal of Electronic Materials, 2008, 37, 1811-1820.	2.2	27
29	Uniform Dispersion of Lanthanum Hexaboride Nanoparticles in a Silica Thin Film: Synthesis and Optical Properties. ACS Applied Materials & Samp; Interfaces, 2012, 4, 5833-5838.	8.0	27
30	Large-Area MEMS Tunable Fabry–Perot Filters for Multi/Hyperspectral Infrared Imaging. IEEE Journal of Selected Topics in Quantum Electronics, 2017, 23, 45-52.	2.9	27
31	Multi-heterojunction large area HgCdTe long wavelength infrared photovoltaic detector for operation at near room temperatures. Journal of Electronic Materials, 1998, 27, 740-746.	2.2	26
32	Diffusion length measurements in p-HgCdTe using laser beam induced current. Journal of Electronic Materials, 2001, 30, 696-703.	2,2	26
33	Mercury cadmium telluride resonant-cavity-enhanced photoconductive infrared detectors. Applied Physics Letters, 2005, 87, 211104.	3.3	26
34	Optical characterization of Fabry-Pe/spl acute/rot MEMS filters integrated on tunable short-wave IR detectors. IEEE Photonics Technology Letters, 2006, 18, 1079-1081.	2.5	26
35	Poisson's Ratio of Low-Temperature PECVD Silicon Nitride Thin Films. Journal of Microelectromechanical Systems, 2007, 16, 622-627.	2.5	26
36	Characterization of Electrically Active Defects in Photovoltaic Detector Arrays Using Laser Beam-Induced Current. IEEE Transactions on Electron Devices, 2005, 52, 2163-2174.	3.0	25

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37	Depth Profiling of Electronic Transport Parameters in n-on-p Boron-lon-Implanted Vacancy-Doped HgCdTe. Journal of Electronic Materials, 2013, 42, 3108-3113.	2.2	25
38	Analysis of crosstalk in HgCdTe p-on-n heterojunction photovoltaic infrared sensing arrays. Journal of Electronic Materials, 1999, 28, 617-623.	2.2	24
39	Dark currents in long wavelength infrared HgCdTe gated photodiodes. Journal of Electronic Materials, 2004, 33, 621-629.	2.2	23
40	Transport properties of reactive-ion-etching-induced p-to-n type converted layers in HgCdTe. Journal of Electronic Materials, 2002, 31, 652-659.	2.2	22
41	Abnormal auditory mismatch fields in adults with autism spectrum disorder. Neuroscience Letters, 2019, 698, 140-145.	2.1	22
42	A novel multi-heterojunction HgCdTe long-wavelength infrared photovoltaic detector for operation under reduced cooling conditions. Semiconductor Science and Technology, 1998, 13, 1209-1214.	2.0	21
43	Low temperature saturation of p–n junction laser beam induced current signals. Solid-State Electronics, 2004, 48, 409-414.	1.4	21
44	Laser beam induced current as a tool for HgCdTe photodiode characterisation. Microelectronics Journal, 2000, 31, 537-544.	2.0	20
45	Scanning laser microscopy of reactive ion etching inducedn-type conversion in vacancy-dopedp-type HgCdTe. Applied Physics Letters, 1997, 70, 3443-3445.	3.3	19
46	Estimation of doping density in HgCdTe p-n junctions using scanning laser microscopy. Applied Physics Letters, 1998, 72, 52-54.	3.3	19
47	Delayed Auditory Evoked Responses in Autism Spectrum Disorder across the Life Span. Developmental Neuroscience, 2019, 41, 223-233.	2.0	19
48	Mercury annealing of reactive ion etching induced p- to n-type conversion in extrinsically doped p-type HgCdTe. Journal of Applied Physics, 1998, 83, 5555-5557.	2.5	18
49	Contribution of hole trap to persistent photoconductivity inn-type GaN. Journal of Applied Physics, 2004, 96, 1019-1023.	2.5	18
50	Environmental stability and cryogenic thermal cycling of low-temperature plasma-deposited silicon nitride thin films. Journal of Applied Physics, 2006, 99, 053519.	2.5	18
51	Small two-dimensional arrays of mid-wavelength infrared HgCdTe diodes fabricated by reactive ion etching-induced p-to-n-type conversion. Journal of Electronic Materials, 2003, 32, 627-632.	2.2	17
52	Annealing of C60o gamma radiation-induced damage in n-GaN Schottky barrier diodes. Journal of Applied Physics, 2007, 101, 054511.	2.5	17
53	Investigation of $1/\!\!f$ Noise Mechanisms in Midwave Infrared HgCdTe Gated Photodiodes. Journal of Electronic Materials, 2007, 36, 884-889.	2.2	17
54	Model and Analysis of a High Sensitivity Resonant Optical Read-Out Approach Suitable for Cantilever Sensor Arrays. Journal of Lightwave Technology, 2012, 30, 1863-1868.	4.6	17

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55	MEMS-Based Tunable Fabry–Perot Filters for Adaptive Multispectral Thermal Imaging. Journal of Microelectromechanical Systems, 2016, 25, 227-235.	2.5	17
56	Evaluation of III–V multilayer transport parameters using quantitative mobility spectrum analysis. Materials Science and Engineering B: Solid-State Materials for Advanced Technology, 1997, 44, 65-69.	3.5	16
57	HgCdTe long-wavelength infrared photovoltaic detectors fabricated using plasma-induced junction formation technology. Journal of Electronic Materials, 2003, 32, 615-621.	2.2	15
58	Passivation effects on reactive-ion-etch-formed n-on-p junctions in HgCdTe. Journal of Electronic Materials, 2002, 31, 743-748.	2.2	14
59	Mercury cadmium telluride/cadmium telluride distributed bragg reflectors for use with resonant cavity-enhanced detectors. Journal of Electronic Materials, 2005, 34, 710-715.	2.2	14
60	Dielectric thin films for MEMS-based optical sensors. Microelectronics Reliability, 2007, 47, 733-738.	1.7	14
61	On-chip read-out of picomechanical motion under ambient conditions. Nanoscale, 2015, 7, 1927-1933.	5.6	14
62	Planar p-on-n HgCdTe heterojunction mid-wavelength infrared photodiodes formed using plasma-induced junction isolation. Journal of Electronic Materials, 2003, 32, 622-626.	2.2	13
63	Crystallization of silicon nitride thin films synthesized by plasma-enhanced chemical vapour deposition. Scripta Materialia, 2007, 57, 739-742.	5.2	13
64	Process Control of Cantilever Deflection for Sensor Application Based on Optical Waveguides. Journal of Microelectromechanical Systems, 2013, 22, 569-579.	2.5	13
65	Investigation of Cerium-Substituted Europium Iron Garnets Deposited by Biased Target Ion Beam Deposition. IEEE Transactions on Magnetics, 2014, 50, 1-7.	2.1	13
66	Ge/ZnS-Based Micromachined Fabry–Perot Filters for Optical MEMS in the Longwave Infrared. Journal of Microelectromechanical Systems, 2015, 24, 2109-2116.	2.5	13
67	Investigation of ICPECVD Silicon Nitride Films for HgCdTe Surface Passivation. Journal of Electronic Materials, 2015, 44, 2990-3001.	2.2	13
68	<title>Erasure of poling-induced second-order optical nonlinearities in silica by UV exposure</title> ., 1994, 2289, 185.		12
69	Correlation of laser-beam-induced current with current-voltage measurements in HgCdTe photodiodes. Journal of Electronic Materials, 2004, 33, 560-571.	2.2	12
70	Determination of mechanical properties of silicon nitride thin films using nanoindentation., 2005, 5798, 216.		12
71	A monolithically integrated HgCdTe short-wavelength infrared photodetector and micro-electro-mechanical systems-based optical filter. Journal of Electronic Materials, 2005, 34, 716-721.	2.2	12
72	Oxidation of PECVD SiNx thin films. Journal of Alloys and Compounds, 2007, 437, 332-338.	5.5	12

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73	Effect of High-Density Plasma Process Parameters on Carrier Transport Properties in p-to-n Type Converted Hg0.7Cd0.3Te Layer. Journal of Electronic Materials, 2007, 36, 913-918.	2.2	12
74	Chemical resistance of porous silicon: photolithographic applications. Physica Status Solidi C: Current Topics in Solid State Physics, 2011, 8, 1847-1850.	0.8	12
75	<title>Isothermal vapor phase epitaxy as a versatile technology for infrared photodetectors</title> ., 1997, 2999, 34.		11
76	Simulation of mid-infrared HgTe/CdTe quantum-well vertical-cavity surface-emitting lasers. Journal of Applied Physics, 1998, 83, 4286-4291.	2.5	11
77	HgCdTe photovoltaic detectors fabricated using a new junction formation technology. Microelectronics Journal, 2000, 31, 545-551.	2.0	11
78	Towards MEMS-based infrared tunable microspectrometers. , 2002, 4935, 148.		11
79	Optical quenching of photoconductivity in undopedn-GaN. Journal of Applied Physics, 2004, 95, 1081-1088.	2.5	11
80	Determination of residual stress in low-temperature PECVD silicon nitride thin films., 2004, 5276, 451.		11
81	High-resolution X-ray diffraction studies of molecular beam epitaxy-grown HgCdTe heterostructures and CdZnTe substrates. Journal of Electronic Materials, 2005, 34, 795-803.	2.2	11
82	Materials and Processes for MEMS-Based Infrared Microspectrometer Integrated on HgCdTe Detector. IEEE Journal of Selected Topics in Quantum Electronics, 2008, 14, 1031-1041.	2.9	11
83	Long-term environmental stability of residual stress of SiNx, SiOx, and Ge thin films prepared at low temperatures. Materials Science and Engineering B: Solid-State Materials for Advanced Technology, 2009, 163, 26-30.	3.5	11
84	Characterization of low-temperature bulk micromachining of silicon using an SF <sub>6</sub> /O <sub>2</sub> inductively coupled plasma. Journal of Micromechanics and Microengineering, 2012, 22, 095005.	2.6	11
85	Large-Area MEMS-Based Distributed Bragg Reflectors for Short-Wave and Mid-Wave Infrared Hyperspectral Imaging Applications. Journal of Microelectromechanical Systems, 2015, 24, 2136-2144.	2.5	11
86	Engineering $1/f$ noise in porous silicon thin films for thermal sensing applications. Microporous and Mesoporous Materials, 2021, 324, 111302.	4.4	11
87	Laser beam induced current imaging of reactive ion etching induced n-type doping in HgCdTe. Journal of Electronic Materials, 1998, 27, 661-667.	2.2	10
88	Wide optical bandwidth asymmetric Fabry–Pérot reflection modulator using the quantum confined Stark effect. Journal of Applied Physics, 1998, 84, 5761-5765.	2.5	10
89	Characterisation of dark current in novel $Hg1\hat{a}^{\circ}$ xCdxTe mid-wavelength infrared photovoltaic detectors based on n-on-p junctions formed by plasma-induced type conversion. Journal of Crystal Growth, 2000, 214-215, 1106-1110.	1.5	10
90	H2-based dry plasma etching for mesa structuring of HgCdTe. Journal of Electronic Materials, 2000, 29, 853-858.	2.2	10

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91	Process condition dependence of mechanical and physical properties of silicon nitride thin films. Journal of Applied Physics, 2007, 102, 103517.	2.5	10
92	Incorporation and activation of arsenic in MBE-grown HgCdTe. Semiconductor Science and Technology, 2008, 23, 015014.	2.0	10
93	A Study of Sidewall Effects in HgCdTe Photoconductors Passivated with MBE-Grown CdTe. Journal of Electronic Materials, 2010, 39, 1019-1022.	2.2	10
94	Mechanochemical Synthesis and Characterization of GaN Nanocrystals. Journal of Nanoparticle Research, 2002, 4, 367-371.	1.9	9
95	Short-wavelength infrared tuneable filters on HgCdTe photoconductors. Optics Express, 2005, 13, 9683.	3.4	9
96	SWIR hyperspectral detection with integrated HgCdTe detector and tunable MEMS filter., 2006, 6295, 113.		9
97	Tunable Fabry-Perot filters operating in the 3 to 5 $\hat{l}$ 4m range for infrared micro-spectrometer applications. , 2006, 6186, 69.		9
98	Adaptive focal plane array (AFPA) technologies for integrated infrared microsystems., 2006, 6232, 70.		9
99	Responsivity and lifetime of resonant-cavity-enhanced HgCdTe detectors. Solid-State Electronics, 2006, 50, 1640-1648.	1.4	9
100	Photoluminescence of HgTeâ^•Hg1â^'x Cdx Tesuperlattices and a study of minibands. Physical Review B, 2007, 75, .	3.2	9
101	MWIR HgCdTe Photodiodes based on high-density plasma-induced type conversion. Semiconductor Science and Technology, 2008, 23, 095027.	2.0	9
102	Arsenic Î-doped HgTeâ-HgCdTe superlattices grown by molecular beam epitaxy. Applied Physics Letters, 2008, 92, 082107.	3.3	9
103	A novel technique for degenerate p-type doping of germanium. Solid-State Electronics, 2013, 89, 146-152.	1.4	9
104	Investigation of crystallized germanium thin films and germanium/silicon heterojunction devices for optoelectronic applications. Materials Science in Semiconductor Processing, 2015, 30, 413-419.	4.0	9
105	Unusually strong excitonic absorption in molecular-beam-epitaxy-grown, chemically lifted GaAs thin films. Physical Review B, 1990, 42, 9496-9500.	3.2	8
106	Multiple-quantum-well reflection modulator using a lifted-off GaAs/AlGaAs film bonded to gold on silicon. Electronics Letters, 1991, 27, 557.	1.0	8
107	Magneto-Transport Characterization of p-Type HgCdTe. Journal of Electronic Materials, 2007, 36, 826-831.	2.2	8
108	Vertical transport in InAs/GaSb type-II strained layer superlattices for infrared focal plane array applications. , 2011, , .		8

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109	Dependence of ohmic contact quality on Au-Ge alloy-thickness for n-type GaAs. International Journal of Electronics, 1984, 57, 729-736.	1.4	7
110	Auî—,Geî—,Ni migration affected by operating conditions of GaAs FETs. Solid-State Electronics, 1984, 27, 447-452.	1.4	7
111	Strain effects in chemically lifted GaAs thin films. Physical Review B, 1990, 41, 7749-7754.	3.2	7
112	Resonant cavity-enhanced mercury cadmium telluride detectors. Journal of Electronic Materials, 2004, 33, 604-608.	2.2	7
113	Some new concepts of heat-flow spreading in GaAs FET structures. International Journal of Electronics, 1984, 57, 155-160.	1.4	6
114	Variable MEMS-based inductors fabricated from PECVD silicon nitride. , 0, , .		6
115	Laser-beam-induced current mapping of spatial nonuniformities in molecular beam epitaxy As-grown HgCdTe. Journal of Electronic Materials, 2004, 33, 572-578.	2.2	6
116	Characterization of crosstalk in HgCdTe n-on-p photovoltaic infrared arrays. , 2004, , .		6
117	Effect of 60 Co gamma-irradiation on two-dimensional electron gas transport and device characteristics of AlGaN/GaN HEMTs. Physica Status Solidi C: Current Topics in Solid State Physics, 2005, 2, 2581-2584.	0.8	6
118	A monolithically integrated HgCdTe SWIR photodetector and tunable MEMS-based optical filter. , 2005, 5783, 719.		6
119	Evaluation of plasma deposited silicon nitride thin films for microsystems technology. Journal of Microelectromechanical Systems, 2005, 14, 971-977.	2.5	6
120	Determination of HgCdTe elasto-plastic properties using nanoindentation. Journal of Electronic Materials, 2006, 35, 1197-1205.	2.2	6
121	Extending the tuning range of SWIR microspectrometers. , 2007, , .		6
122	Elasto-plastic characterisation of low-temperature plasma-deposited silicon nitride thin films using nanoindentation. International Journal of Surface Science and Engineering, 2009, 3, 3.	0.4	6
123	Nanostructural Characteristics and Mechanical Properties of Low Temperature Plasma Enhanced Chemical Vapor Deposited Silicon Nitride Thin Films. Journal of Nanoscience and Nanotechnology, 2009, 9, 3734-3741.	0.9	6
124	Integrated Resonant Optical Readout Applicable to Large Arrays of MEMS Beams. IEEE Photonics Technology Letters, 2012, 24, 2243-2246.	2.5	6
125	Effect of CdS Processing Conditions on the Properties of CdS/Si Diodes and CdS/CdTe Thin-Film Solar Cells. IEEE Journal of Photovoltaics, 2015, 5, 1783-1790.	2.5	6
126	Optimization of ICPCVD Amorphous Silicon for Optical MEMS Applications. Journal of Microelectromechanical Systems, 2015, 24, 1998-2007.	2.5	6

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127	Ultrathin-film ohmic contacts for GaAs FET. Journal Physics D: Applied Physics, 1983, 16, L243-L245.	2.8	5
128	A simplified fabrication process for HgCdTe photoconductive detectors using CH4/H2reactive-ion-etching-induced blocking contacts. Semiconductor Science and Technology, 2001, 16, 455-462.	2.0	5
129	Investigation of laser beam-induced current techniques for heterojunction photodiode characterization. Journal of Applied Physics, 2005, 98, 034501.	2.5	5
130	Investigation of HgTe-HgCdTe superlattices by high-resolution X-ray diffraction. Journal of Electronic Materials, 2006, 35, 1481-1486.	2.2	5
131	MEMS-based Fabry-Perot microspectrometers for agriculture. Proceedings of SPIE, 2009, , .	0.8	5
132	Silicon-Air-Silicon Distributed Bragg Reflectors for Visible and Near Infrared Optical MEMS. Journal of Microelectromechanical Systems, 2015, 24, 1245-1247.	2.5	5
133	Photostriction actuation of silicon-germanium bilayer cantilevers. Journal of Applied Physics, 2019, 125, .	2.5	5
134	A bistable MOSFET-type metal-tunnel insulator-semiconductor switch. IEEE Electron Device Letters, 1981, 2, 121-122.	3.9	4
135	Design of externally tuned asymmetric fibre Fabry–Perot electroabsorption optical modulators. IEE Proceedings: Optoelectronics, 1998, 145, 344-352.	0.8	4
136	<title>Tunable Fabry-Perot cavities</title> ., 2000,,.		4
137	Transferable silicon nitride microcavities. Microelectronics Journal, 2000, 31, 523-529.	2.0	4
138	Finite element analysis of tunable Fabry Perot MEMS structures. , 0, , .		4
139	Minority carrier lifetime and noise in abrupt molecular-beam epitaxy-grown HgCdTe heterostructures. Journal of Electronic Materials, 2003, 32, 639-645.	2.2	4
140	Stress Response of Low Temperature PECVD Silicon Nitride Thin Films to Cryogenic Thermal Cycling. , 0, , .		4
141	CHARACTERISTICS OF LOW TEMPERATURE PECVD SILICON NITRIDE FOR MEMS STRUCTURAL MATERIALS. International Journal of Modern Physics B, 2006, 20, 3799-3804.	2.0	4
142	Micro-electromechanical systems-based microspectrometers covering wavelengths from $1500 \text{nm}$ to $5000 \text{nm}$ , $2007$ , , .		4
143	MEMS-based tunable Fabry-Perot filters on silicon substrates. Optoelectronic and Microelectronic Materials and Devices (COMMAD), Conference on, 2008, , .	0.0	4
144	Deposition heating effect on CdS thin films prepared by thermal evaporation for CdTe solar cells. , 2014, , .		4

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145	Suspended Large-Area MEMS-Based Optical Filters for Multispectral Shortwave Infrared Imaging Applications. Journal of Microelectromechanical Systems, 2015, 24, 1102-1110.	2.5	4
146	Preparation and Characterization of Cerium Substituted Bismuth Dysprosium Iron Garnets for Magneto-Optic Applications. IEEE Transactions on Magnetics, 2016, 52, 1-4.	2.1	4
147	A monolithic dual-band HgCdTe infrared detector structure. IEEE Electron Device Letters, 1997, 18, 352-354.	3.9	3
148	$$ $$ $$ $$ $$ $$ $$ $$ $$		3
149	Nano-indentation characterisation of PECVD silicon nitride films. , 0, , .		3
150	Chemical structure of low-temperature plasma-deposited silicon nitride thin films. , 2004, , .		3
151	Dark current modelling of midwave infrared HgCdTe gated photodiodes. , 2006, , .		3
152	MEMS-based microspectrometers for infrared sensing. , 2007, , .		3
153	Widely tunable Fabry-Perot optical filter using fixed-fixed beam actuators. , 2008, , .		3
154	OPTICAL MEMS TECHNOLOGIES FOR ELECTRICALLY TUNABLE MULTI-SPECTRAL SHORT-WAVE INFRARED SENSORS AND ARRAYS. International Journal of High Speed Electronics and Systems, 2008, 18, 1035-1044.	0.7	3
155	Thermally induced damages of PECVD SiNx thin films. Journal of Materials Research, 2011, 26, 2552-2557.	2.6	3
156	Near band-edge field-dependent absorption coefficient and refractive index determined by photocurrent and transmittance measurements. Applied Optics, 1999, 38, 5127.	2.1	2
157	<title>Anomalous drain current-voltage characteristics in AlGaN/GaN MODFETs at low temperatures</title> ., 1999,,.		2
158	RIE-induced n-on-p junction HgCdTe photodiodes: effects of passivant technology on bake stability., 2001, 4454, 106.		2
159	The effects of vacuum baking on the I-V characteristics of LWIR HgCdTe photodiodes., 2004,,.		2
160	Uniformity in HgCdTe diode arrays fabricated by reactive ion etching. Journal of Electronic Materials, 2004, 33, 141-145.	2.2	2
161	Accurate determination of composition profiles in abrupt MBE-grown HgCdTe heterostructures. , 2004, , .		2
162	Fabry-Perot MEMS microspectrometers spanning the SWIR and MWIR., 2007,,.		2

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163	Photoresponse in photoconductor devices fabricated from HgTe-HgCdTe superlattices. Applied Physics Letters, 2011, 98, 043505.	3.3	2
164	Electrical type conversion of p-type HgCdTe induced by nanoimprinting. Journal of Applied Physics, 2011, 109, 096102.	2.5	2
165	Fabrication process for optically low loss Si cantilever waveguide. , 2011, , .		2
166	Modeling and Design of a Thin-Film CdTe/Ge Tandem Solar Cell. Journal of Electronic Materials, 2012, 41, 2759-2765.	2.2	2
167	Recent developments towards low-cost MEMS spectrometers. , 2014, , .		2
168	Characterization and Modeling of Photostriction in Silicon Cantilevers Fabricated on Silicon-on-Insulator Substrates. Journal of Microelectromechanical Systems, 2015, 24, 182-191.	2.5	2
169	<title>Transferable silicon nitride microcavities</title> ., 1999, 3892, 142.		1
170	Anomalous drain current–voltage characteristics in AlGaN/GaN MODFETs at low temperatures. Microelectronics Journal, 2000, 31, 531-536.	2.0	1
171	Towards a laser beam induced current test structure for the nondestructive determination of junction depth in HgCdTe photodiodes. , 0, , .		1
172	Diffusion length measurements using laser beam induced current. , 0, , .		1
173	<title>60Co gamma-irradiation-induced defects in MOCVD n-GaN</title> ., 2001, , .		1
174	Non-contact evaluation of photodiode performance by laser beam induced current imaging. , 0, , .		1
175	Noise modeling in HgCdTe heterostructure devices. Journal of Applied Physics, 2003, 94, 6541-6548.	2.5	1
176	Investigation of Surface Passivation of HgCdTe MWIR Photodiode Arrays via a Flood Illumination Technique. , 0, , .		1
177	Mechanical Design and Finite Element Analysis of Tunable Fabry-Perot MEMS Structures for Adaptive Infrared Detectors. , 0, , .		1
178	High density plasma processing of p-Hg <inf>0.7</inf> Cd <inf>0.3</inf> Te., 2006,,.		1
179	Design and optimisation of a MEMS-based tunable Fabry-Pérot infrared filter. , 2006, , .		1
180	Thermal Stability of PECVD SiN/sub x/ Films. , 2006, , .		1

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181	Characterisation of arsenic doped HgCdTe grown by Molecular Beam Epitaxy. , 2006, , .		1
182	Crystallization and compositional changes in amorphous PECVD SiN $\boldsymbol{x}$ thin films. , 2007, , .		1
183	Real-time mass spectroscopy of reflected fluxes during molecular beam epitaxy growth of HgCdTe. Journal of Vacuum Science & Technology B, 2008, 26, 1068.	1.3	1
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